Since its first synthesis in 1959, the HgCdTe semiconductor alloy system has proven to be a remarkably versatile intrinsic infrared detector material. A wide variety of high performance HgCdTe infrared detectors have been demonstrated and developed, including photoconductors, homojunction and heterojunction photodiodes, and metal-insulator-semiconductor photovoltaic devices. Controlled variations in HgCdTe alloy composition have enabled cutoff wavelengths to be tailored over the 2-25 μm wavelength region.

The success that HgCdTe has achieved is rooted in a unique set of semiconductor properties that make it a nearly ideal infrared detector material. Its large optical absorption coefficient enables (internal) quantum efficiencies approaching 100% to be achieved in devices that are 12-15 μm thick. Long carrier lifetimes allow the highest operating temperatures for achieving a given detectivity at a given cutoff wavelength.

This paper will review the status of LWIR HgCdTe detector technology for wavelengths between 8 and 17 μm, for application in NASA and DoD focal plane arrays (FPAs) operating at temperatures near 65 K with mission lifetimes of 5 to 10 years.

Linear arrays of LWIR HgCdTe photoconductors have been in production for the past ten years for DoD applications such as scanning thermal imaging systems and missile seekers. These arrays contain as many as 180 elements, operate at 77 K and cover the 8 to 12 μm wavelength region, which corresponds to a Hg_{1-x}Cd_xTe alloy composition of x=0.21. These arrays are usually fabricated from bulk-grown n-type HgCdTe crystals having donor concentrations of 2-5 E14 cm^-3. Detector sensitivity is typically background limited, with detectivities of 0.6-1.5E11 cm-Hz^{1/2}/W. Device resistances are typically 40 ohms per square at 77 K, with dc power dissipations of 0.1-0.5 mW. The total U.S. industry capacity for these units is about 2500-3000 deliveries per month.

LWIR HgCdTe photoconductors represent a mature established technology that will continue to play an important role in NASA and DoD applications that require relatively small numbers of elements (less than several hundred) which do not require a multiplexer on the focal plane. For example, Loral provided a large-area HgCdTe photoconductor with a detectivity of 3E10 cm-Hz^{1/2}/W at 16 μm for the ATMOS interferometer.

Advanced DoD and NASA applications require orders of magnitude more detectors in a focal plane array. For these applications, HgCdTe photovoltaic (PV) devices are the detectors of choice because their higher impedance enables them to match into low-noise silicon CMOS input amplifiers. NxM arrays of HgCdTe photovoltaic detectors on IR-transparent substrates are bump interconnected to matching NxM arrays of input circuits on silicon CMOS multiplexer chips to form large focal lenses.
plane arrays. LWIR FPAs for scanning applications are typically 128 to 256 elements long, with 4, 8 or 16 elements in the scan direction for signal-to-noise enhancement, and have pixel sizes on the order of 50 μm x 50 μm. LWIR staring FPAs typically have 64x64 or 128x128 formats, with unit cells usually less than 50 μm x 50μm.

These advanced LWIR FPAs place stringent performance requirements on the HgCdTe photovoltaic detector arrays in terms of zero-bias impedance, reverse-bias impedance and leakage current, quantum efficiency, fill factor, crosstalk, 1/f noise, uniformity of response and reliability.

Initial LWIR HgCdTe photovoltaic detectors were planar n-on-p devices made by mercury-diffusion and ion implantation. More recently, substantial improvements in device performance have been achieved with the use of a double-layer P-on-n LPE heterojunction photodiodes grown onto CdTe substrates. These LPE heterojunctions have demonstrated performance which approaches the theoretical limit set by n-side diffusion current at temperatures of 80 to 70 K over the 10-19 μm range.

Major improvements have been made over the years in HgCdTe materials technology. At Loral, uniformity of alloy composition in both bulk-grown and LPE HgCdTe is such that variations in detector cutoff wavelength are less than ±1% over the 2-12 μm range.

In this paper, the performance requirements that today's advanced LWIR focal plane arrays place on the HgCdTe photovoltaic detector array will be summarized. The theoretical performance limits for intrinsic LWIR HgCdTe detectors will be reviewed as functions of cutoff wavelength and operating temperature. The status of LWIR HgCdTe photovoltaic detectors will be reviewed and compared to the FPA requirements and to the theoretical limits. Emphasis will be placed on recent data for two-layer HgCdTe LPE heterojunction photodiodes grown at Loral with cutoff wavelengths ranging between 10 and 19 μm at temperatures of 70 - 80 K. Development trends in LWIR HgCdTe detector technology will be outlined, and conclusions will be drawn about the ability for photovoltaic HgCdTe detector arrays to satisfy a wide variety of advanced focal plane array applications.
Status of LWIR HgCdTe Infrared Detector Technology

M.B. Reine
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Innovative Long Wavelength Infrared Detector Workshop
April 24 - 26, 1990
Jet Propulsion Laboratory
California Institute of Technology
Pasadena, California 91109

Status of LWIR HgCdTe Detector Technology

EMPHASIS
- Wavelength: 10 to 17 μm
- Operating temperature: 60 K to 65 K
- Future NASA and DoD long-duration space applications

TOPICS:
1. HgCdTe material properties for infrared detectors
   - Uniformity of Hg_x Cd_y Te alloy composition
2. Theoretical limits to HgCdTe detector performance and operating temperature
   - Thermal g-r noise
   - Background g-r noise
3. Detector requirements for advanced focal plane arrays
4. Status of HgCdTe infrared detectors:
   - Photoconductors
   - Photodiodes
5. Development trends in HgCdTe materials and devices
Success of HgCdTe as an Infrared Detector Material Is Due to Its Energy Band Structure

- Adjustable energy band gap covers the 1-25 μm IR region
- Direct interband transitions give quantum efficiencies approaching 100% for 15 μm thick devices
- Intrinsic recombination mechanisms give long carrier lifetimes and high operating temperatures

The Hg₉ₓCdₓTe Semiconductor Alloy System Possesses Many Desirable Properties for an Infrared Detector Material

- Continuously adjustable energy gap from -0.3 eV to 1.6 eV
- Large absorption coefficient for high quantum efficiency
- Small lattice mismatch: 0.3% between HgTe and CdTe
- Amphoteric (can be made n-type or p-type):
  - Foreign atom donors and acceptors
  - Native defect acceptors
- Large electron-to-hole mobility ratio (400 for x=0.2 at 77K)
- Electrical purity levels of less than 1E14 cm⁻³
- Surfaces are compatible with many passivation approaches:
  - ZnS, SiO₂
  - Native (anodic) oxide, sulphide or fluoride
  - Wide-gap HgCdTe
The $\text{Hg}_y\text{Cd}_x\text{Te}$ Semiconductor Alloy System Possesses Many Desirable Properties for an Infrared Detector Material (continued)

- Long minority carrier lifetimes:
  - p-type: Shockley-Read, Auger 7
  - n-type: Auger 1, Shockley-Read

- Favorable thermal expansion coefficient:
  - Good match to silicon
  - Excellent match to GaAs, sapphire

- Low dielectric constant for low junction capacitance

- Compatible with many advanced crystal growth techniques:
  - Bulk: Honeywell's DME; THM
  - LPE: from Hg-rich and Te-rich solutions
  - VPE: MOCVD, MBE

Detector Cutoff Wavelength for $\text{Hg}_1-x\text{Cd}_x\text{Te}$ Devices

$$\lambda_{\text{co}} (\mu\text{m}) = \frac{1.24}{E_v (\text{eV})}$$

$E_v (x, T)$ from:

Hansen, Schmit, Casselman
Today’s Hg$_{1-x}$Cd$_x$Te has Excellent Uniformity of Alloy Composition

HgCdTe Device Technology

PHOTOCONDUCTORS
- n-type and p-type
- Signal Processing In The Element (SPRITE)
- Photo-JFET structures with gain enhancement

PHOTODIODES
- Homojunctions: n-on-p and p-on-n
- Heterojunctions: N-on-p and P-on-n
- Avalanche photodiode for 1.3 to 1.6 $\mu$m

PHOTOCAPACITORS
- n-channel and p-channel Charge Coupled Devices
- Charge Imaging Matrix

OTHER
- n-channel Insulated-Gate Field Effect Transistors
- Spin-flip Raman laser
Noise in A Two-Level Detector

\[ n(t) = n_0 + n_B + \delta n(t) \]

\[ p(t) = p_0 + p_a + \delta p(t) \]

\[ g_r, g_i \text{ Theorem (Burgess, 1954):} \]

\[ \delta n(t) = \frac{1}{Ad} \left[ \frac{n_p}{n_0 + p_0} + \frac{T}{\tau} \right] \delta n_B + \frac{1}{Ad} \left[ \frac{n_i}{n_0} + \frac{Q_B}{d} \right] \delta n_0 \]

\[ n_p, n_i = n'_r \text{ (Eq. T)} \]

\[ \frac{1}{\tau} = \frac{\delta}{\delta n} \text{ (Eq. g)} \]

\[ \delta n(t) = \delta p(t) \]

LWIR PC HgCdTe Sensitivity vs Temperature
LWIR PC HgCdTe Status

- Transit-limited response times of 0.5 \( \mu \text{sec} \)
- Photoconductive gain = 200
- DC bias power = 0.1-0.3 mW
- 60-180 element linear arrays in full production (capacity: 600 units/month):
  - \( T = 77 \text{ K} \)
  - \( \lambda_{\text{peak}} = 11.8 \mu\text{m} \)
  - \( \lambda_{\text{eq}} = 13.0 \mu\text{m} \)
  - \( D^* = 6 \times 10^{10} - 1.4 \times 10^{11} \text{ cm-Hz}^{1/2}/\text{W} \) (BLIP for \( Q_e = 0.3 - 1 \times 10^{17} \text{ ph/cm}^2\text{-s} \))
  - 1/f noise knee frequencies less than 50 - 100 Hz
  - Area = 50 \( \mu\text{m} \times 50 \mu\text{m} \)
- DME bulk-grown Hg\(_{1-x}\)Cd\(_x\)Te material:
  - \( x \)-uniformity: \( \Delta x = \pm 0.0005 \rightarrow \Delta \lambda_{\text{eq}} (77 \text{ K}, 12.5 \mu\text{m}) = \pm 0.1 \mu\text{m} \)
  - Electrical purity: \( 1 \times 10^{14} \text{ cm}^{-3} \)
- Passivation by anodic oxide surface accumulation:
  - Surface recombination velocity < 500 cm/s
  - Shunt resistance = 70 \( \Omega/\square \)

Generalized Backside-Illuminated HgCdTe Focal Plane Array
The Photon Detection Process in LWIR Focal Plane Arrays

1. Photoexcitation of electrons or electron-hole pairs
2. Transport and recombination of photoexcited carriers: drift, diffusion, charge separation
3. Interaction with the external "input" circuit
4. Signal conditioning within each unit cell: amplification, integration, filtering, sampling
5. Multiplexing
6. Signal processing with uncooled electronics off the focal plane: nonuniformity compensation, sub-frame integration

Detector Requirements for LWIR Focal Plane Arrays

1. Cutoff Wavelength: Today: 10.5 - 12.0 μm
   Desired: out to 19 μm (e.g., AIRS)
2. Operating Temperature: 60-80 K (always as high as possible)
3. Detectivity: Usually BLIP: 1E11 cm-Hz^{1/2}/W
4. Impedance: High; 10 to 20 times larger than for BLIP
5. Quantum Efficiency: > 70%
6. Active Area: 35 μm x 35 μm to 100 μm x 100 μm
7. 1/f Noise: Critical for staring FPAs (BW=0.1 - 10 Hz)
8. Uniformity:
   - cutoff wavelength: ± 0.1 - 0.2 μm
   - quantum efficiency: ± 10%
   - impedance: depends on input circuit design
Detector Requirements for LWIR Focal Plane Arrays (Continued)

9. Bias Voltage: -10 mV to -40 mV for direct injection
   0 ± 0.5 mV with active offset control
10. Crosstalk: < 2 - 3%
11. Fill Factor: > 80% for staring FPAs
12. Linearity: ± 2%
13. Dynamic Range: 1E4-1E5
14. Frequency Response: Not an issue
15. Environmental Stability: Thermal cycling; shock; vibration
16. Radiation Hardness: Total dose; various particles

Simplified Input Coupling Model for Hybrid FPA

\[ D^* = \frac{q\eta\lambda}{hc} \sqrt{\frac{A}{\eta\phi A}} \left( 2q^2 + \frac{4kT}{R} + \frac{e^2}{R^2} \right)^{-1/2} \]

- \( e_* \) = amplifier (or input gate) noise voltage
- \( A \) = detector area
- \( R \) = detector zero bias resistance

(Assumes coupling efficiency \( \approx 1.0 \))
Key Focal Plane
Requirements for AIRS Instrument

**FPA SENSITIVITY REQUIREMENTS**

- Configuration
  - Multiple linear arrays
  - 8 SWIR Bands: 3.4 to 8.0 μm
  - 8 LWIR Bands: 8.0 to 15.4 μm (17.0 μm Goal)
- Pixel Size: 200 μm x 100 μm
- Total Pixel Count: 3950
- Background Flux Density: ≤2E15 ph/cm²-s (LWIR)
- Minimum Operating Temp: 60 K
- Thermal Heat Load ≤ 500 mW
- Outages ≤2%
- Reliability ≥0.99 at 5 years
- Total Dose ≤ 2E4 rads (Si)
- Technology Cutoff: 1992 1st instrument

**REQUIRED RweetsA PRODUCTS FOR AIRS PV DETECTORS**

- 

![Graph](image-url)

- 

**ORIGINAL PAGE IS OF POOR QUALITY**
P-N Junction Formation in HgCdTe

1968
Hg-Diffused \( n^\text{-on-p} \)
- Hg-vacancy acceptors

1975
Ion-implanted \( n^\text{+}-on-p \) (\( n^\text{+} \cdot n^\text{-on-p} \))
- implant damage
- native & foreign acceptors

1982
LPE grown heterojunctions
- N-on-p
- P-on-n

1987
Acceptordiffused p-on-n
- diffusion sources:
  - ion implant
  - Hg-solution

1990
MOCVD grown heterojunctions

BACKSIDE-ILLUMINATED P-on-n LPE HgCdTe
HETEROJUNCTION PHOTODIODES
VLWIR P-on-n LPE HgCdTe Heterojunction Film Grown at Loral

![Graph of relative spectral response and quantum efficiency vs. microns.]

VLWIR P-on-n LPE HgCdTe Heterojunction Film Grown at Loral

![Graph of relative response (per watt) vs. microns for LD 025FB at 80 K with λ_{50} = 16.8 μm.]
I. INTRINSIC MECHANISMS
   • Diffusion Current (Thermally Generated Current)
     - n-side
     - p-side
   • Band-to-Band Tunneling current (Zener Tunneling)
     - Can be eliminated near zero bias by low doping

II. DEFECT-MEDIATED MECHANISMS
   • Generation-Recombination (g-r) current
   • Trap-Assisted Tunneling Current
   • Defects may be at surface or within bulk

Dark Current Mechanisms in HgCdTe p-n Junction Photodiodes

![Diagram of a p-n junction diode with labels for diffusion and g-r current equations.]

**DIFFUSION CURRENT:**
\[
\frac{1}{R_A} = \frac{e\mu_n d}{kTn_e^2}
\]

**G-R CURRENT:**
\[
\frac{1}{R_A} = \frac{\phi}{V_m} \frac{\mu_e W}{\tau_e}
\]
LORAL
Infrared & Imaging Systems

LWIR LPE P-on-n HgCdTe Photodiodes Grown at Loral

N-SIDE DIFFUSION CURRENT AUGER-1 LIFETIME
$N_0 = 2 \times 10^{15} \text{cm}^{-3}$

$D'_\lambda = 1 \times 10^{12} \text{cm-Hz}^{1/2}/\text{W}$
$T = 80 \text{K}$

$D'_\lambda = 1 \times 10^{11} \text{cm-Hz}^{1/2}/\text{W}$
$T = 80 \text{K}$

$D'_\lambda$ Limited by thermal noise:

$$D'_\lambda \approx \frac{\lambda}{hc} \eta \sqrt{\frac{R_o A}{4 kT}}$$

CUTOFF WAVELENGTH (µm)

LORAL P-on-n PV HgCdTe

$\bullet$ $T = 70 \text{K}$

$\circ$ $T = 80 \text{K}$

Bilinear Array ER02C2

10.58 µm at 72 K

Ave Rbb = 2.71 Amp/Watt
Std Dev = 4.9%
1 open in 83 elements accessed

RoA at 72K
RoA at 80K
Rbb at 72K

Element Number

75
Bilinear Array ER02D4
10.68 μm at 72 K

Ave Rbb = 2.75 Amp/Watt
Std Dev = 5.1%
83 elements accessed

LWIR P-on-n HgCdTe PV Array

T = 70 K
λ_{co} = 11.6 μm
Δ -40 mV reverse bias
0 zero bias voltage
Trends in HgCdTe Materials Growth

1. LOWER GROWTH TEMPERATURE AND LAYERED GROWTH:

<table>
<thead>
<tr>
<th>Temperature</th>
<th>Technique</th>
</tr>
</thead>
<tbody>
<tr>
<td>700 °C</td>
<td>Solid state recrystallization</td>
</tr>
<tr>
<td></td>
<td>Honeywell’s DME</td>
</tr>
<tr>
<td></td>
<td>Traveling heater method</td>
</tr>
<tr>
<td>400 °C - 500 °C</td>
<td>Liquid Phase Epitaxy</td>
</tr>
<tr>
<td></td>
<td>Te-Rich</td>
</tr>
<tr>
<td></td>
<td>Hg-Rich</td>
</tr>
<tr>
<td>150 °C - 300 °C</td>
<td>MOCVD</td>
</tr>
<tr>
<td>120 °C - 195 °C</td>
<td>MBE</td>
</tr>
</tbody>
</table>

2. FOREIGN SUBSTRATES:

CdTe → CdTeSe → Sapphire → GaAs → GaAs on Si
CdZnTe

Conclusions

1. HgCdTe has nearly ideal semiconductor properties for LWIR detection
2. Alloy composition uniformity of today’s bulk-grown and LPE HgCdTe is more than adequate
3. LWIR HgCdTe P-on-n LPE heterojunction photodiode performance is at the limit set by n-side diffusion current for Auger-1 lifetime for T > 70 K
4. Continued development of HgCdTe material and device technology will:
   a. Improve performance:
      • Reduced leakage current and 1/f noise
      • Longer cutoff wavelengths
   b. Increase producibility:
      • Low-cost large-area substrates
      • Improved screening techniques for material and arrays
   c. Enable in situ VPE growth of advanced device structures:
      • p-n homojunctions and heterojunctions
      • Wide-gap passivation
      • Low-resistivity contact layers